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SUBJECT: SERIAL NO. : 10/065,714

RESPONSE TO OFFICE ACTION MAILED ON 06/27/2003

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Winston Hsu 2003/9/24

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APPLICATION NUMBER: 10/065,714

PAPERS INCLUDED:

(1) Transmittal Form	1 PAGE
(2) Fee Transmittal	1 PAGE
(3) Response to the Office Action	14 PAGES

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TRANSMITTAL FORM <i>(to be used for all correspondence after initial filing)</i>	Application Number	10/065,714	
	Filing Date	11/13/2002	
	First Named Inventor	Chu-Ming Cheng	
	Group Art Unit	2851	
	Examiner Name	Nguyen, Michelle P	
Total Number of Pages in This Submission	16	Attorney Docket Number	OTMP0028USA

ENCLOSURES <i>(check all that apply)</i>		
<input checked="" type="checkbox"/> Fee Transmittal Form <input type="checkbox"/> Fee Attached <input checked="" type="checkbox"/> Amendment / Reply <input type="checkbox"/> After Final <input type="checkbox"/> Affidavits/declaration(s) <input type="checkbox"/> Extension of Time Request <input type="checkbox"/> Express Abandonment Request <input type="checkbox"/> Information Disclosure Statement <input type="checkbox"/> Certified Copy of Priority Document(s) <input type="checkbox"/> Response to Missing Parts/Incomplete Application <input type="checkbox"/> Response to Missing Parts under 37 CFR 1.52 or 1.53	<input type="checkbox"/> Assignment Papers (for an Application) <input checked="" type="checkbox"/> Drawing(s) <input type="checkbox"/> Licensing-related Papers <input type="checkbox"/> Petition <input type="checkbox"/> Petition to Convert to a Provisional Application <input type="checkbox"/> Power of Attorney, Revocation Change of Correspondence Address <input type="checkbox"/> Terminal Disclaimer <input type="checkbox"/> Request for Refund <input type="checkbox"/> CD, Number of CD(s) _____	<input type="checkbox"/> After Allowance Communication to Group <input type="checkbox"/> Appeal Communication to Board of Appeals and Interferences <input type="checkbox"/> Appeal Communication to Group (Appeal Notice, Brief, Reply Brief) <input type="checkbox"/> Proprietary Information <input type="checkbox"/> Status Letter <input type="checkbox"/> Other Enclosure(s) (please identify below):
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**FEE TRANSMITTAL
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☐ Applicant claims small entity status. See 37 CFR 1.27**TOTAL AMOUNT OF PAYMENT** (\$) 0.00**Complete if Known**

Application Number	10/085,714
Filing Date	11/13/2002
First Named Inventor	Chu-Ming Cheng
Examiner Name	Nguyen, Michelle P
Art Unit	2851
Attorney Docket No.	OTMP0028USA

METHOD OF PAYMENT (check all that apply)☐ Check ☐ Credit card ☐ Money Order ☐ Other ☐ None☒ Deposit Account:

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FEE CALCULATION**1. BASIC FILING FEE**

Large Entity Fee Code (\$)	Small Entity Fee Code (\$)	Fee Description	Fee Paid
1001 750	2001 375	Utility filing fee	
1002 330	2002 165	Design filing fee	
1003 820	2003 260	Plant filing fee	
1004 750	2004 375	Reissue filing fee	
1005 160	2005 80	Provisional filing fee	
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2. EXTRA CLAIM FEES FOR UTILITY AND REISSUE

Large Entity Fee Code (\$)	Small Entity Fee Code (\$)	Fee Description	Fee Paid
1202 18	2202 9	Claims in excess of 20	
1201 84	2201 42	Independent claims in excess of 3	
1203 280	2203 140	Multiple dependent claim, if not paid	
1204 84	2204 42	** Reissue independent claims over original patent	
1205 18	2205 9	** Reissue claims in excess of 20 and over original patent	
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FEE CALCULATION (continued)**3. ADDITIONAL FEES**

Large Entity Small Entity

Fee Code (\$)	Fee Code (\$)	Fee Description	Fee Paid
1051 130	2051 65	Surcharge - late filing fee or oath	
1052 50	2052 25	Surcharge - late provisional filing fee or cover sheet	
1053 130	2053 130	Non-English specification	
1812 2,620	1812 2,620	For filing a request for ex parte reexamination	
1804 920*	1804 920*	Requesting publication of BIR prior to Examiner action	
1805 1,840*	1805 1,840*	Requesting publication of BIR after Examiner action	
1251 110	2251 55	Extension for reply within first month	
1252 410	2252 205	Extension for reply within second month	
1253 930	2253 465	Extension for reply within third month	
1254 1,450	2254 725	Extension for reply within fourth month	
1255 1,970	2255 985	Extension for reply within fifth month	
1401 320	2401 160	Notice of Appeal	
1402 320	2402 160	Filing a brief in support of an appeal	
1403 290	2403 140	Request for oral hearing	
1451 1,510	1451 1,510	Petition to institute a public use proceeding	
1452 110	2452 55	Petition to revive - unavoidable	
1453 1,300	2453 650	Petition to revive - unintentional	
1501 1,300	2501 650	Utility issue fee (or reissue)	
1502 470	2502 235	Design issue fee	
1503 630	2503 315	Plant issue fee	
1480 130	1480 130	Petitions to the Commissioner	
1807 50	1807 50	Processing fee under 37 CFR 1.17(c)	
1806 180	1806 180	Submission of Information Disclosure Stmt	
8021 40	8021 40	Recording each patent assignment per property (times number of properties)	
1809 760	2809 375	Filing a submission after final rejection (37 CFR 1.129(a))	
1810 760	2810 375	For each additional invention to be examined (37 CFR 1.129(b))	
1801 750	2801 375	Request for Continued Examination (RCE)	
1802 900	1802 900	Request for expedited examination of a design application	

Other fee (specify)

*Reduced by Basic Filing Fee Paid

SUBTOTAL (3) (\$) 0.00**SUBMITTED BY**

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9/24/2003

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MARKED UP VERSION OF SPECIFICATION

ILLUMINATING SYSTEM AND METHOD FOR IMPROVING

ASYMMETRIC PROJECTION

5 CROSS REFERENCE TO RELATED APPLICATION

This application incorporates by reference Taiwanese application Serial No. 90128276, filed on 11/15/2001.

BACKGROUND OF THE INVENTION

10 [0001]1. Field of the Invention

[0002] The present invention relates to a projection system and, more particularly, to an illuminating system and method for improving asymmetric projection in a projection system.

[0003]2. Description of Related Art

15 [0004] Referring to FIG. 1, a projection system 20 in a prior art is a single panel full color system having a light source 21 with a parabolic concave reflector 211 to emit a white light beam 23. After reflected by the parabolic concave reflector 211, the white light beam 23 passes through a converging lens 22 to converge the light beam 23 on a color wheel 24. When rotating around a shaft, the color wheel 24 has a
20 sequence of red, green, and blue filters to intercept the light beam 23 in order, so the light beam 23 shifts into a color light beam 25 as passing through the color wheel 24. Then, the color light beam 25 transmits in order through an integration rod 26, a condenser lens 27, a stop 28, and a relay lens 29 to impinge in a prism 30, and a mirror 31 in the prism 30 reflects the color light beam 25 to a light valve 10, such as
25 Digital Micro-mirror Device (hereinafter referred to as "DMD"). Therefore, the light

valve 10 modulates the color light beam 25 to generate an image light and reflects the image light into a projection lens 32 for projecting an image onto a screen (not shown).

[0005] The DMD has an array of inclinable mirrors corresponding to an array of pixels constituting the image. When one of inclinable mirrors reflects a light beam to the screen, the inclinable mirrors is referred to as "on-state"; when reflecting a light beam off the screen, the pixel mirror is referred to as "off-state"; when the pixel mirror parallel the DMD board, that is between the on-state and the off-state, the pixel mirror is referred to as "flat-state".

[0006] FIG. 2 shows a second projection system 40 in a prior art. The difference, between the first projection system 20 and the second projection system 40, is that the light source 41 of the second projection system 40 has an elliptic concave reflector 411. The elliptic concave reflector 411 reflects and converges a light beam, emitted from the light source 41, to a color wheel 44 without passing a converging lens. For the rest, the second projection system 40 is the same as the first projection system 20 and actually is one embodiment of the first projection system 20. To simplify the description, the first projection system 20 was only described as an example in the following specification, but its technologies can be fully suitable for the second projection system 40.

[0007] In the first projection system 20, from the light source 21 to the light valve 10, the light beam passes through any optical element, such as the converging lens 22, the color wheel 24, integration rod 26, the condenser lens 27, the stop 28, and the relay lens 29, having the geometrically symmetric feature. Therefore, as shown in FIG. 3, before obliquely impinging onto the light valve 10, the light beam has a

rectangular cross section to form a rectangular-sectional light beam 51 with a feature of an intensely uniform illumination. If any above-mentioned optical elements and their assembly are perfect, the length of a first diagonal L1 will be equal to that of a second diagonal L2 on the rectangular-sectional light beam 51, i.e. the rectangular-sectional light beam 51 has no distortion.

[0008] Referring to FIG. 4, when the rectangular-sectional light beam 51, passing through the prism 30, obliquely impinges onto the light valve 10, a light spot 52 is formed thereon. Consequently, the light spot 52 is distorted due to the inclined incidence, so that the length of the first diagonal L1 isn't equal to that of the second diagonal L2, i.e. $L1 > L2$.

[0009] The above-mentioned prior art has at least two drawbacks as follows: one reduces the uniform brightness of the light spot resulted from the unequal extension of two diagonals; the other causes the brightness loss on circumference of the light spot from the extension of the first diagonal L1 out of the light valve and results in decreasing the illumination efficiency.

SUMMARY OF THE INVENTION

[0010] One objective of the present invention is to provide a method for offsetting two asymmetric diagonals of the distorted light spot. By the use of an [anamorphic] asymmetrically curved surface unit of a projection system, the method will improve the asymmetric light spot resulted from the inclined incidence to achieve a more symmetric light spot.

[0011] The other objective of the present invention is to use an [anamorphic] asymmetrically curved surface unit for producing two asymmetric orthogonal axes so that an illuminating system can generate a parabolic-sectional light beam with a

smaller F-number. Thus, that can avoid the overlap of light beams between on-state and flat-state to raise the contrast. Furthermore, by amplifying the light spot, the projection system will increase the total illumination efficiency of the optic system.

5

BRIEF DESCRIPTION OF DRAWINGS

[0012] FIG. 1 is a schematic view showing a light path of a first projection system in the prior art;

[0013] FIG. 2 is a schematic view showing a light path of a second projection system in the prior art;

10

[0014] FIG. 3 is a schematic cross-sectional view showing a non-distortion rectangular light beam of a first projection system in the prior art before the light beam obliquely impinges onto the light valve;

[0015] FIG. 4 is a schematic view showing a distorted rectangular light spot on the light valve in the prior art;

15

[0016] FIG. 5(A)-5(C) is a schematic view showing an improving procedure by the use of an [anamorphic] asymmetrically curved surface unit;

[0017] FIG. 6(A)-6(B) is a spot diagram respectively showing a brightness distribution of the light spot of the prior art and the present invention on DMD;

20

[0018] FIG. 7(A)-7(B) is a schematic view showing the axial-extended elliptic light spot on the stop;

[0019] FIG. 8 is a schematic view showing the relative positions of the open-state, off-state, and flat state of the light beam on the spot of the projection lens;

[0020] FIG. 9(A)-9(B) is a spot diagram respectively showing the brightness distribution of the screen of the prior art and the present invention.

[0021] FIG. 10 is an experimental data list showing the contrast between the present invention and the prior art.

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

[0022] Referring to the drawings, the present invention will be described in a following embodiment. For solving a distortion of the prior art, the present invention is to provide an [anamorphic] asymmetrically curved surface unit for offsetting the distortion formed by two asymmetric diagonals of a light spot, so that the asymmetric light spot, resulting from inclined incidence of a projection system, can be improved into a more symmetric light spot.

[0023] Referring to FIG.1, an embodiment of the invention has the same projection system and light path as the first projection system 20 of the prior art. That is, the embodiment of the invention includes the light source 21 producing a light beam 23 to form a light path. The light beam 23 successively passes through the reflector 211, the converging lens 22, the color wheel 24, integration rod 26, the condenser lens 27, the stop 28, the relay lens 29, prism 30, and the mirror 31. Then, the light beam 23 obliquely impinges to the light valve 10 and finally reflects to the projection lens 32 to project an image onto the screen. The difference, between the embodiment of the invention and the first projection system 20, is that the embodiment of the invention has an asymmetrically curved surface unit placed in the light path between the light source 21 and the light valve 10. In general, the [anamorphic] asymmetrically curved surface unit may be formed on one surface of a lens, reflector, or mirror. Concretely, the [anamorphic] asymmetrically curved surface unit may be formed on any surface of the reflector 211, converging lens 22, condenser lens 27, relay lens 29, or mirror 31 [of the projection system shown in FIG. 1].

[0024] Referring to FIG. 5(A)-5(C), [The anamorphic]the asymmetrically curved surface unit 291 is formed on one surface of the relay lens 29 in this embodiment, for example. [Referring to FIG. 5(A)-5(C),] FIG. 5(B) shows the relay lens 29 as a rectangular [anamorphic] and asymmetrically curved lens, [having] which

5 has one normal surface 292 and another convex asymmetrically curved surface unit 291 [surface] with larger curvature at X-axis than Y-axis. FIG. 5(A) shows the distorted light spot 53 on DMD, in which two diagonals at M and N direction is asymmetric each other, and the length of the N-direction diagonal is longer than that of the M-direction diagonal. When using the [anamorphic lens replaces] relay lens 29

10 with the asymmetrically curved surface unit 291, the X-axis of the [anamorphic] asymmetrically curved surface unit 291 [lens] is in the N-direction of the distorted light spot, and the Y-axis is in the M- direction. Therefore, by means of the different amplifying rates due to the different curvature of the X-axis and the Y-axis, the length of the N-direction diagonal can be shortened to improve the asymmetric light spot on

15 DMD for achieving a more symmetric light spot 54, shown in FIG. 5(C). In the same principle, by the use of the [anamorphic] asymmetrically curved surface unit 291 with the different curvature, the light spot 54 can appropriately be symmetrized or produced a predetermined distortion.

[0025] Referring to FIG. 6, FIG. 6(A) shows a DMD spot diagram of the prior

20 art without an [anamorphic] asymmetrically curved surface unit. Due to the inclined incidence, the light spot of the prior art generates a distortion and appears a diagonal extension from the down-left to up-right corner. That is, the length of the first diagonal L1 is longer than that of the second diagonal L2, shown in FIG. 4. On the contrary, FIG. 6(B) shows a DMD spot diagram of the present invention with an [anamorphic]

5 asymmetrically curved surface unit. By using an [anamorphic] asymmetrically curved surface unit to offset the distortion resulting from inclined incidence, a more symmetric light spot can be achieved. In contrast with the asymmetric light spot, the extension on the diagonal of the DMD light spot, shown in FIG. 6(B), have been improved obviously.

[0026] Furthermore, because the light beam on DMD can only be reflected to the screen through the rear-end projection lens, an available rectangular region need to be defined for matching the DMD within the light spot shown in FIG. 6(A) and 6(B). Owing to the producing tolerance, the available rectangular region is slightly larger
10 than the DMD and has the same ratio of length and width as that of the DMD in order to make sure that the light beam can illuminate all DMD. Therefore, the illuminating loss area, between the peripheries of the available rectangular and the asymmetric DMD light spot in the prior art, is larger than that of the present invention, so the total light collection efficiency of the prior art is less than that of the present invention.

15 [0027] Referring to FIG. 7(A) and 7(B), FIG. 7(A) shows that the light spot on the stop of projection lens 32 is a circle spot due to the relay lens 29 without an [anamorphic] asymmetrically curved surface unit in prior art. FIG. 7(B) shows the light spot on the stop of projection lens 32 due to the relay lens 29 with an [anamorphic] asymmetrically curved surface unit. Because the relay lens 29 has the
20 [anamorphic] asymmetrically curved surface with the different curvatures in X-axis and Y-axis to produce different amplifications, the light spot extends different lengths along the X-axis and Y-axis and forms an elliptic spot. Therefore, the Y-axis length of the light spot on the stop of projection lens 32 is elongated clearly, so that the shape of the light spot transforms a circular into an ellipse to increase the total light collection

efficiency of projection system. The technology of the present invention will be described in detail as follows.

[0028] FIG. 8 shows the relative positions of the on-state, off-state, and flat state of the light beam at the stop of the projection lens 32. The solid line respectively represents the on-state light beam 61, flat state light beam 62, and off-state light beam 63 of the prior art, and the dotted line respectively represents the on-state light beam 64, flat-state light beam 65, and off-state light beam 66 of the present invention. In theory, the bigger the on-state light beam 61 is, the more light [flex] flux can be allowed to enter into the stop for achieving better brightness. If the on-state light beam 61 is enlarged to produce a light spot 611 having the same size as the stop 67, the flat-state light beam 62 and off-state light beam 63 will also be enlarged as light spot 68 and 69 respectively. That causes the some overlaps between light spot 611 and light spot 68 to decrease the projection contrast. Therefore, the on-state light beam 61, flat state light beam 62, and off-state light beam 63 of the prior art are set to be next to each other and have no X-axial overlap between them, so that the maximum light flux can be allowed to pass without the sacrifice of contrast to achieve the best balance.

[0029] The present invention uses an [anamorphic] asymmetrically curved surface unit for producing two asymmetric orthogonal axes to offset the distorted light spot formed by the inclined incidence of the prior art, so as to achieve a more symmetric light spot. Meanwhile, the present invention may also use the feature of two asymmetric orthogonal axes to extend the light spot of the on-state light beam 64, flat-state light beam 65, and off-state light beam 66 along Y-axis. Then, the diaphragm of the present invention is enlarged (i.e. the F number decreases). The on-state light beam 64, flat state light beam 65, and off-state light beam 66 of the present invention

can respectively replace the on-state light beam 61, flat state light beam 62, and off-state light beam 63 of the prior art. Thus, the present invention can make sure that the elliptic light beam with the larger maximum light flux pass without any loss, and avoid the overlaps between the on-state light beam 64, flat -state light beam 65, and
5 off-state light beam 66.

[0030] FIG. 9(A) and FIG. 9(B) respectively show the screen brightness distribution diagrams of the prior art and the present invention when the light beam on the DMD reflects onto the screen through the rear-end projection lens. As a result, the deep color, shown in FIG. 9(B), representing the high brightness distribution region of
10 the present invention is larger than that of the prior art, as shown in FIG. 9(A), in the brightness region and uniformity of the screen diagram. Furthermore, the X-axis and Y-axis brightness distribution of the present invention is also indeed more uniform than that of the prior art in the screen diagram.

[0031] Referring to FIG. 10, the experimental data list shows the contrast
15 between the present invention and the prior art. The experimental datum includes the percentages of DMD efficiency DMD, overfill, the projection output efficiency of on-state, and the projection output efficiency of flat-state. The right columns of the list show the improving rate of the present invention compared with that of the prior art. As to the improving rates of the present invention, the DMD efficiency is 4.6%; the
20 overfill loss is 16.8%; the projection output efficiency of on-state is 2.9%; the projection output efficiency of flat-state is 69.2 %.

[0032] Although the reflective DMD is a example for describing the above preferred embodiments, it can be replaced with a Liquid Crystal On Silicon (LCOS) or
a Liquid Crystal Display (LCD) panel.

[0033] The invention has been described using exemplary preferred
embodiments. However, it is to be understood that the scope of the invention is not
limited to the disclosed embodiments. On the contrary, it is intended to cover various
modifications and similar arrangements. The scope of the claims, therefore, should be
5 accorded the broadest interpretation so as to encompass all such modifications and
similar arrangements.

Marked Up Version of claim**WHAT IS CLAIMED IS:**

1. [The] A system for improving asymmetric projection comprising:
 - a light source producing a light beam to form a light path;
 - 5 a projection lens which is disposed in the light path and projects an image [onto a screen];
 - a light valve inserted in the light path between the light source and the projection lens, which receives the light beam obliquely impinging from the light source to form a light spot, selects and reflects the [obliquely incident] light [beam]
 - 10 spot to the projection lens or predetermined directions; and
 - at least one [anamorphic] asymmetrically curved surface unit placed in the light path between the light source and the light valve, which has different curvatures on surface to offset the distortion of the light spot resulting from obliquely impinging.
- 15 [2. The system for improving asymmetric projection of claim 1, further comprising a mirror disposed in the light path between the light vale and the anamorphic surface unit.]
- [3. The system for improving asymmetric projection of claim 1, wherein the light valve is a Liquid Crystal On Silicon (LCOS).]
- 20 4. The system for improving asymmetric projection of claim 1, wherein the light valve is a Digital Micro-mirror Device (DMD).
- [5. The system for improving asymmetric projection of claim 1, wherein the light valve is a Liquid Crystal Display (LCD) panel.]
6. The system for improving asymmetric projection of claim 1, wherein the

[anamorphic] asymmetrically curved surface unit is an [anamorphic] asymmetrically curved lens.

[7. The system for improving asymmetric projection of claim 1, wherein the anamorphic surface unit is a reflector.]

5 8. The system for improving asymmetric projection of claim 1, further comprising a reflector, a converging lens, a condenser lens, a relay lens, and a mirror between the light source and the light valve, wherein the [anamorphic] asymmetrically curved surface unit can be any one surface of [a] the reflector, converging lens, condenser lens, relay lens, [and]or mirror.

10 [9. The method for improving asymmetric projection, comprising:

a light source for producing a light beam to form a light path;

a light valve for receiving the light beam with oblique incidence to generate a light spot with two asymmetric diagonals thereon; and

at least one anamorphic surface unit, in the light path between the light source and

15 the light valve, having a curvature for offsetting two asymmetric diagonals of the light spot into a more normal rectangle.]

[10. The method for improving asymmetric projection of claim 9, wherein the anamorphic surface unit is an anamorphic lens.]

20 [11. The method for improving asymmetric projection of claim 9, wherein the anamorphic surface unit is a reflecting surface.]

12. The [method] system for improving asymmetric projection of claim [9]4, wherein the [anamorphic] asymmetrically curved surface unit has a curvature in predeterminate axis for elongating the Y-axial length of the light spot in on-state, flat-state, and off-state in order to form non-overlapping elliptic light beams.

25

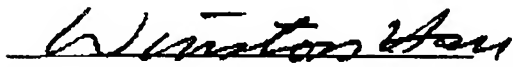
Marked Up Version of Abstract

An illuminating system and method for improving asymmetric projection
[comprising]~~comprise~~ a light source producing a light beam to form a light path, a
projection lens disposed in the light path, a light valve inserted in the light path
5 between the light source and the projection lens, and at least one [anamorphic]
asymmetrically curved surface unit placed in the light path between the light source
and the light valve. The [anamorphic] asymmetrically curved surface unit offsets a
distortion of a light spot resulted from obliquely incidence on the light valve, thus an
asymmetric light spot can be improved as a more symmetric one to increase
10 illuminating collection efficiency and uniformity.

15

Sincerely yours,

20



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25

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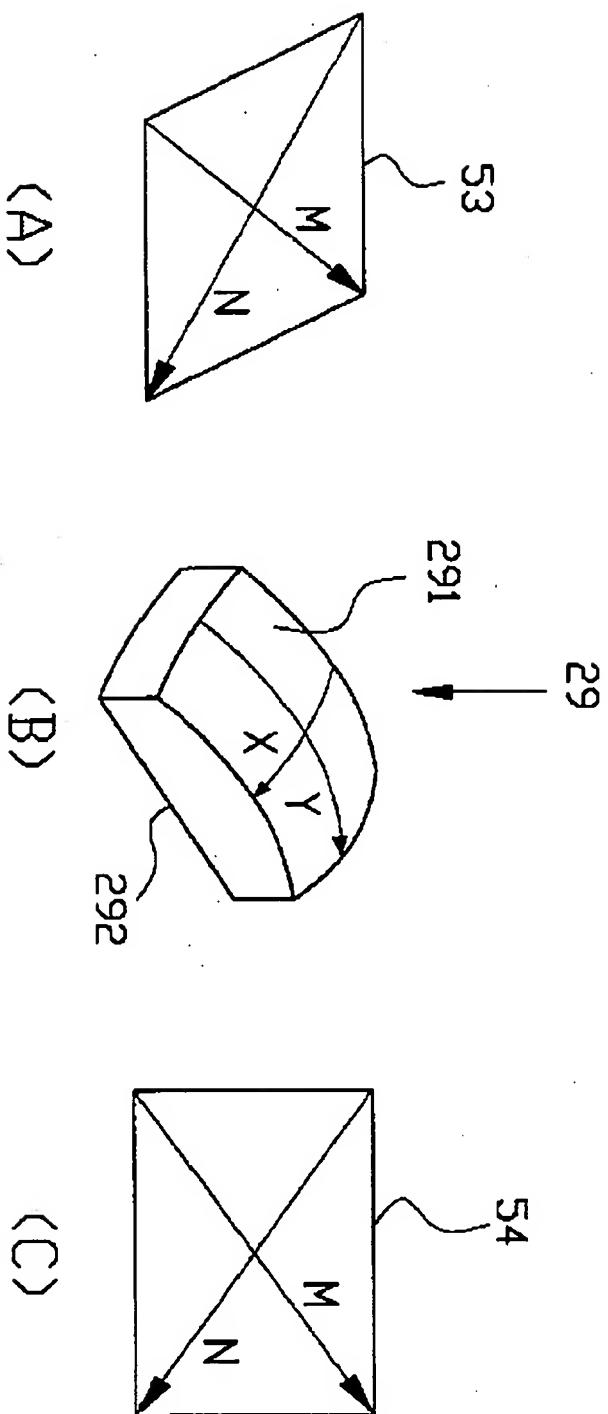


FIG. 5